# **Astrella**

## **Ultrafast Ti:Sapphire Amplifier**

Astrella and the new Astrella HE are next-generation, ultrafast, kHz amplifiers that are the first to combine industry-leading performance and industrialized durability. Manufactured to Coherent's rigorous standards using advanced stress-testing techniques, the one-box Astrella system enables a wide range of demanding scientific applications and operating conditions, offering higher productivity and lower data acquisition costs. Delivering high (up to >9 mJ/pulse) energy, a range of pulse-width options from <35 fs to <100 fs, and excellent beam quality (M² <1.25), Astrella is ideal for ultrafast spectroscopy, THz studies, femtosecond micromachining, etc. With unmatched performance, reliability and affordability, Astrella stands at the forefront of the industrial revolution in ultrafast science.



### **FEATURES**

- One-box, industrialized platform
- HASS (Highly Accelerated Stress Screening) verified for quality and reliability
- >5 mJ, >7 mJ or >9 mJ pulse energies
- <35 fs, <60 fs, <80 fs, or <100 fs pulse width options
- High performance STAR regen amplifier (water-only cooling)
- Hands-free Vitara oscillator
- Revolution pump laser for performance overhead
- Sealed stretcher/compressor section with advanced dispersion management for clean, short pulses
- Thermally-stabilized sub-systems for long term stability

### **APPLICATIONS**

- Time-resolved Spectroscopy
- Multidimensional Spectroscopy
- THz Spectroscopy
- fs Micromachining
- Surface SFG/SHG
- Stimulated Raman Scattering
- High Harmonic Generation
- EUV Spectroscopy

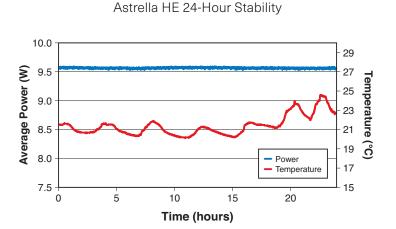


Specifications <sup>1</sup>	Astrella USP	Astrella F	Astrella HE USP	Astrella HE F
Center Wavelength <sup>2</sup> (nm) (nominal)	795 to 805	780 to 820	795 to 805	780 to 820
Repetition Rate <sup>3</sup> (kHz)	1,5			
Pulse Duration <sup>3,4</sup> (fs) (FWHM)	<35	<60, <80, <100	<35	<60, <80, <100
Contrast Ratio <sup>5</sup> Pre-Pulse Post-Pulse	>1000:1 >100:1			
Power Stability <sup>6,7</sup> (rms)	<0.5			
Beam Pointing Stability <sup>6,7</sup> (µrad) (rms)	<10			
Beam Diameter (mm) (1/e²) (nominal) 1 kHz 5 kHz	11		13 11	
Spatial Mode	TEM <sub>00</sub> , M <sup>2</sup> <1.25			
Polarization	linear, horizontal			
Energy per Pulse (mJ) 1 kHz 5 kHz		>5.0, >7.0		
Pump Laser	Revolution-50	, Revolution-65	Revolution-80	
Seed Laser	Vitara-S, Vitara-T, or Vitara-T-HP			
Each System HASS Verified	Yes			

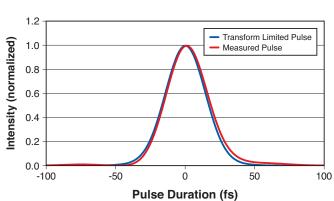
#### Notes:

- 1. Specifications apply at 800 nm.
- 2. Factory set, must be specified when ordered and will be optimized prior to shipment.
- 3. Contact factory for other repetition rates and pulse width options.
- 4. A Gaussian pulse shape de-convolution factor (0.7) is used to determine the pulse width from an autocorrelation signal measured by a Coherent SSA (Single-Shot Autocorrelator).
- 5. Contrast ratio is defined as the ratio between the peak intensity of the output pulse to the peak intensity of any other pulse that occurs greater than 1 ns before or after the output pulse.
- 6. Under stable environmental conditions after system warm-up.
- 7. Over 24 hrs.

### **Typical Performance Data**



# Astrella HE USP Pulse Width

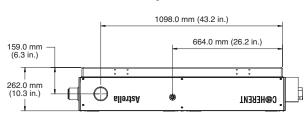




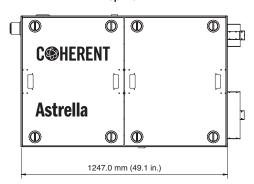
### **Mechanical Specifications**

### Astrella

### **Right Side View**



### **Top View**



#### Rear View

